



**ALPHA & OMEGA**  
SEMICONDUCTOR

# ***Alpha & Omega Semiconductor Product Reliability Report***

**AOZ5276QI** rev A

**Plastic Encapsulated Device**

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The AOS product reliability report summarizes the qualification results for AOZ5276QI in QFN5x6-39L package. Accelerated environmental tests are performed on a specific sample size, samples are electrically tested before and after each stress time point. Review of final electrical test results confirm that AOZ5276QI pass the AOS quality and reliability requirements. The released products will be categorized by its process family and routinely monitored for continuous improvement of product quality.

## I. Reliability Stress Test Summary and Results

Test Item	Test Condition	Time Point	Sample Size / Lots	Number of Failures	Reference Standard
HTOL	$T_J = 150^{\circ}\text{C}$ , $V_{IN} = 25\text{V}$	168 / 500 / 1000 hours	231 pcs (3 lots)	0	JESD22-A108
Preconditioning (Note A)	$T_A = 85^{\circ}\text{C}$ , RH = 85% + 3 cycle reflow @ $260^{\circ}\text{C}$ (MSL 1)	168hours	924 pcs (3 lots)	0	JESD22-A113
HAST	$T_A = 130^{\circ}\text{C}$ , RH = 85%, P = 33.3psia, $V_{IN} = 25\text{V}$	96 hours	231 pcs (3 lots)	0	JESD22-A110
Autoclave	$T_A = 121^{\circ}\text{C}$ , RH = 100%, P = 29.7psia	96 hours	231 pcs (3 lots)	0	JESD22-A102
Temperature Cycle	$T_A = -65^{\circ}\text{C}$ to $150^{\circ}\text{C}$ , air to air	500 / 1000 cycles	231 pcs (3 lots)	0	JESD22-A104
HTSL	$T_A = 150^{\circ}\text{C}$	1000 hours	231 pcs (3 lots)	0	JESD22-A103
Power Cycling	$V_{IN} = 19\text{V}$ , $V_{OUT} = 1.0\text{V}$ , $F_{SW}$ = 600kHz, $I_{OUT} = 30\text{A}$ , VCC cycled 0V-5V @ 1hz	24hrs, >86k cycles	10 pcs (3 lots)	0	AOS Standard
HTGB (MOSFET)	$T_J = 150^{\circ}\text{C}$ , $V_{GS} = 12\text{V}$	168 / 500 / 1000 hours	231 (3 lots)	0	JESD22-A108
HTRB (MOSFET)	$T_J = 150^{\circ}\text{C}$ , $V_{DS(HS)} = 30\text{V}$ , $V_{DS(LS)} = 25\text{V}$	168 / 500 / 1000 hours	231 (3 lots)	0	JESD22-A108
HT3RB (MOSFET)	$T_A = 130^{\circ}\text{C}$ , RH = 85%, P = 33.3psia, $V_{DS(HS)} = 30\text{V}$ , $V_{DS(LS)} = 25\text{V}$	168 / 500 / 1000 hours	231 (3 lots)	0	JESD22-A101
Validation	3 cycle reflow @ $260^{\circ}\text{C}$ + 250 cycles @ $T_A = -65^{\circ}\text{C}$ to $150^{\circ}\text{C}$	250 cycles	3000 (3 lots)	0	AOS Standard
Mechanical Shock	Condition B a = 2000g, t = 0.5ms 5 shocks per side, 6 sides	30 shocks / device	15	0	JESD22-B110

**Note:** The reliability data presents total of available generic data up to the published date.  
 Note A: MSL (Moisture Sensitivity Level) 1 based on J-STD-020

## II. Reliability Evaluation

The presentation of FIT rate for the individual product reliability is restricted by the actual burn-in sample size of the product technology. Failure Rate Determination is based on JEDEC Standard JESD 85.

**FIT rate (failures per billion device hours): 0.190**

**MTTF = 5,251.7 million hrs**

**Condition:**  $V_o = 20V$ ,  $T_o = 55^\circ C$ ,  $V_{s(DriverIC)} = 25V$ ,  $V_{s(MOSFET)} = 30V/25V$  and  $T_s = 150^\circ C$

**Sample Size:** MOSFET = 6,153, Driver IC = 3,874

The failure rate ( $\lambda$ ) is calculated as follows:

$$\lambda = \chi^2[CL, (2f+2)] / 2 \times [1 / (SS \times t \times AF)]; \text{ [equation 1]} \quad \text{where} \quad \begin{array}{l} CL = \% \text{ of confidence level} \\ f = \text{number of failure} \\ SS = \text{sample size} \\ t = \text{stress time} \end{array}$$

Looking up the  $\chi^2/2$  table for zero failure (burn-in) with 60% confidence, the value of  $\chi^2[CL, (2f+2)] / 2$  is 0.92.

The Acceleration Factor (AF) is calculated from the following formula (both temperature and voltage acceleration factors are used in the final acceleration factor calculation) :

$$AF = AF_T \times AF_V = \exp[(E_a/k) \times (1/T_o - 1/T_s)] \times \exp[\beta (V_s - V_o)] \quad \text{where} \quad \begin{array}{l} E_a = \text{activation energy} \\ k = \text{Boltzmann constant} \\ T_o = \text{operating } T_J \\ T_s = \text{stress } T_J \\ V_s = \text{stress voltage} \\ V_o = \text{operating voltage} \\ \beta = \text{voltage acceleration coefficient} \end{array}$$

Assuming typical operating environment,  $V_o = 20V$ ,  $T_o = 55^\circ C$ ,  $E_a = 0.7eV$ ,  $V_{s(DriverIC)} = 25V$ ,  $V_{s(MOSFET)} = 30V/25V$ ,  $T_s = 150^\circ C$ ,  $\beta = 0.5$  (silicon defect)

$$\begin{aligned} AF(DriverIC) &= \exp \left[ \left( \frac{0.7}{8.617E - 5} \right) \cdot \left( \frac{1}{273 + 55} - \frac{1}{273 + 150} \right) \right] \cdot \exp[0.5 \cdot (25V - 20V)] \\ AF(HS MOSFET) &= \exp \left[ \left( \frac{0.7}{8.617E - 5} \right) \cdot \left( \frac{1}{273 + 55} - \frac{1}{273 + 150} \right) \right] \cdot \exp[0.5 \cdot (30V - 20V)] \\ AF(LS MOSFET) &= \exp \left[ \left( \frac{0.7}{8.617E - 5} \right) \cdot \left( \frac{1}{273 + 55} - \frac{1}{273 + 150} \right) \right] \cdot \exp[0.5 \cdot (25V - 20V)] \end{aligned}$$

Substituting the values in equation 1, we have  $\lambda = \lambda(HS MOSFET) + \lambda(LS MOSFET) + \lambda(IC) =$

$$0.92 \cdot \frac{2}{\text{Sample Size} \cdot \text{Stress Duration} \cdot AF(MOSFET)} + \frac{1}{\text{sample Size} \cdot \text{Stress Duration} \cdot AF(DriverIC)} \text{ hr}^{-1}$$

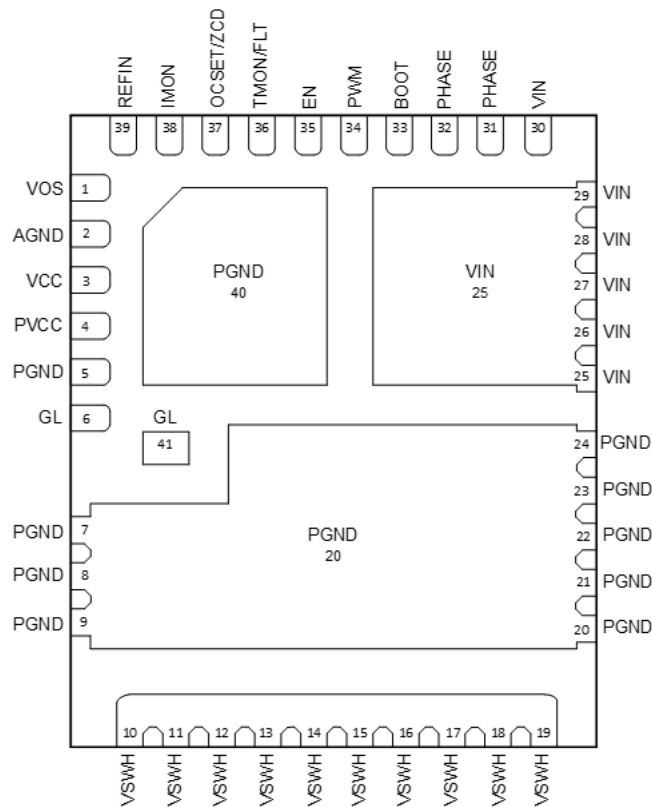
$\lambda = 0.190 \cdot 10^{-9} \text{ hr}^{-1}$  or 0.190 FIT;  $MTTF = (1/\lambda) = 5,251.7 \text{ million hrs} = 599,511 \text{ years}$

The calculation shows failure rate is 0.190 FIT, MTTF is 5,251.7 million hours under typical operating conditions.

### III. ESD and Latch Up Test Results

Test	Test Conditions	Total Sample Size	Number of Failures	Reference Standard
Electrostatic Discharge Human Body Model	T <sub>A</sub> = 25°C, +/-2kV	10	0	JESD-A114
Electrostatic Discharge Charged Device Model	T <sub>A</sub> = 25°C, +/-1kV	10	0	JESD-C101
Latch Up	T <sub>A</sub> = 25°C, +/-100mA, 1.5x OV	10	0	JESD78
Latch Up	T <sub>A</sub> = 125°C, +/-100mA, 1.5x OV	10	0	JESD78

**Note:** ATE results are used to determine PASS/FAIL. Parametric shift<10%.



**QFN5x6-39L  
(Top View)**